

L Number	Hits	Search Text	DB	Time stamp
1	491	((interconnect wire wiring metallization metallisation . metalization metalisation metal) near4 taper\$4) near12 (insulation insulating ILD dielectric)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/20 12:09
2	143	((((interconnect wire wiring metallization metallisation metalization metalisation metal) near4 taper\$4) near12 (insulation insulating ILD dielectric)) and (349/\$ 438/\$ 257/\$).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/20 12:10